

Data Analysis and Control of a MeV Ultrafast Electron Diffraction System using Machine Learning

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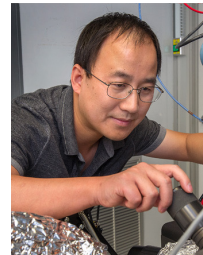
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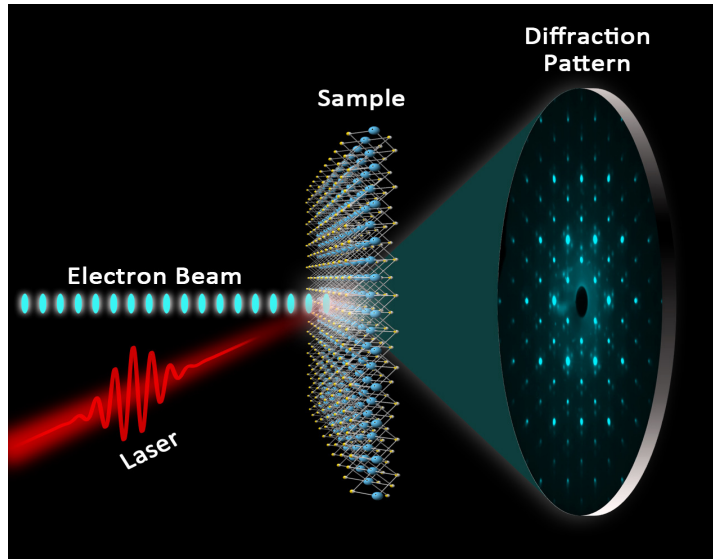


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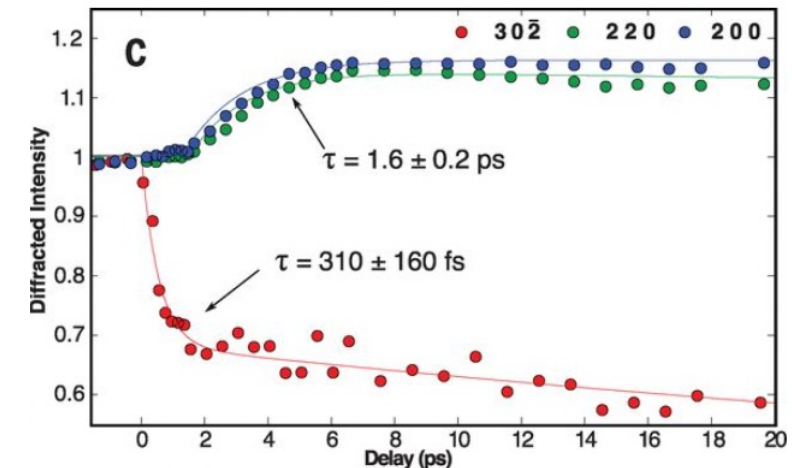
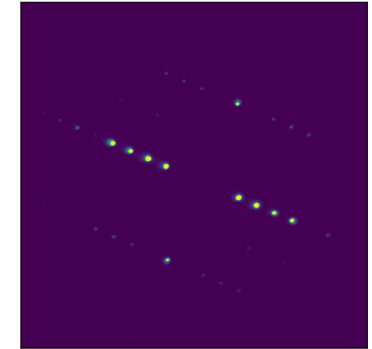


MeV ultrafast electron diffraction (MUED)

It is a powerful structural measurement technique for exploring time-resolved, ultrafast processes in different material systems.



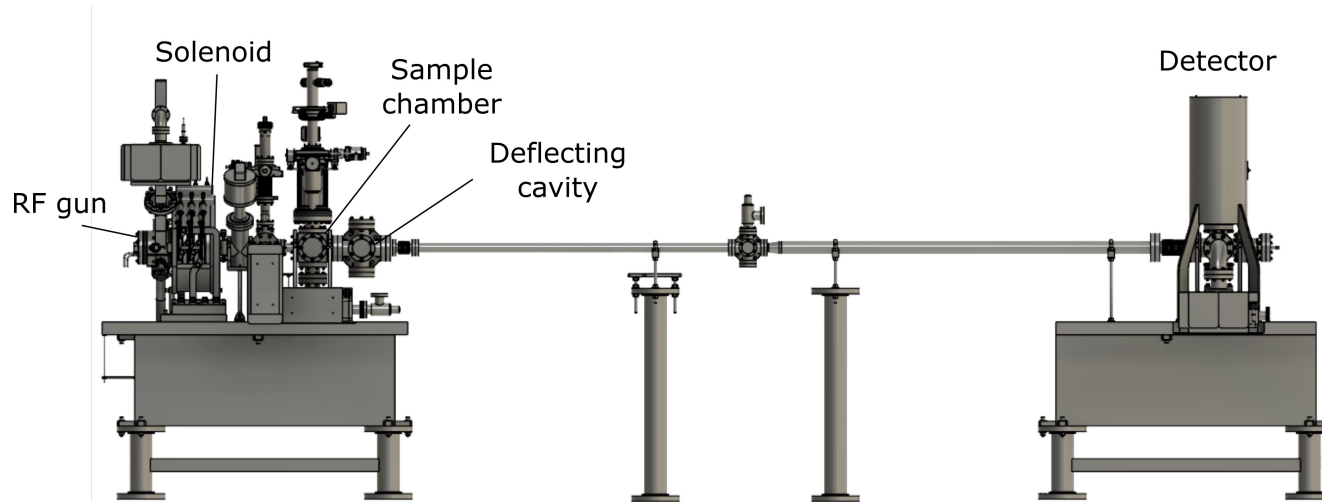
- ✓ Diffraction measurements made at time scales below 10 fs
- ✓ High scattering cross-section
- ✓ Extremely short wavelength (diffraction patterns contain many reflections)
- ✓ Reduced space charge effects
- ✓ Less multiple scattering effects (structural reconstruction sometimes possible)



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Accelerator Test Facility (ATF @ BNL)



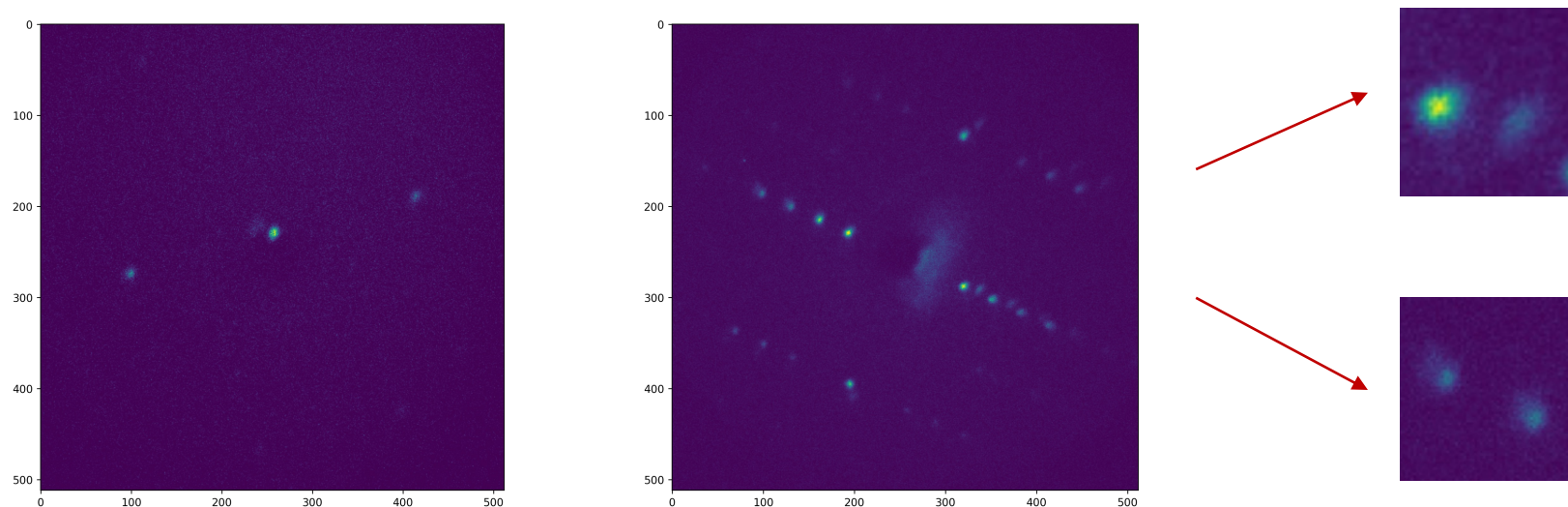
Beam energy	3 MeV
N e- per pulse	1.25×10^6
Temporal resolution	180 fs
Beam diameter	300 (100 best) μm
Max repetition rate	5 – 48 Hz
N e- per sec per μm^2	88-880

- Ti:Sapph pump (but OPA available, up to 9 μm)
- Liquid Ni or liquid He cooling
- Strict sample requirements (electron transparent, lateral size > 300 nm)

Why do we need machine learning for analysis?

- Due to instabilities in the electron beam, **anomalous** patterns are usually observed in single shot mode.
- These anomalies are integrated when accumulating several patterns (typically 70) and will be detrimental for the accuracy of the experiment.

- Some examples:



- The rate of anomalies is about 10% but can vary largely with experimental conditions (eg: 38% anomaly rate in a pump-probe experiment).

We want to be able to find anomalous patterns in the large datasets with no user input (autonomous)

- We have different types of anomalies and would like to also recognize unseen types.
 - We will limit our analysis to Ta_2NiSe_5 as it is single crystal.
 - The anomalies are under sampled, we can't employ a classification model.
- We developed a convolutional autoencoder model to reconstruct the diffraction patterns.
 - Our model trains on all data (unsupervised).
 - An anomaly will have a large reconstruction error or different feature vector values.
 - We tested different strategies to detect anomalies.

Input: images of 512 x 512 pixels.

1. We split each image in 80 x 80 pixels tiles, using a sliding window with overlap.
2. Filter out the tiles are background, for this we devised a simple algorithm to decide if a tile contains white noise:

For $f(x)$ a discrete distribution of N samples that is normalized, we define the inverse participation ratio (IPR) as:

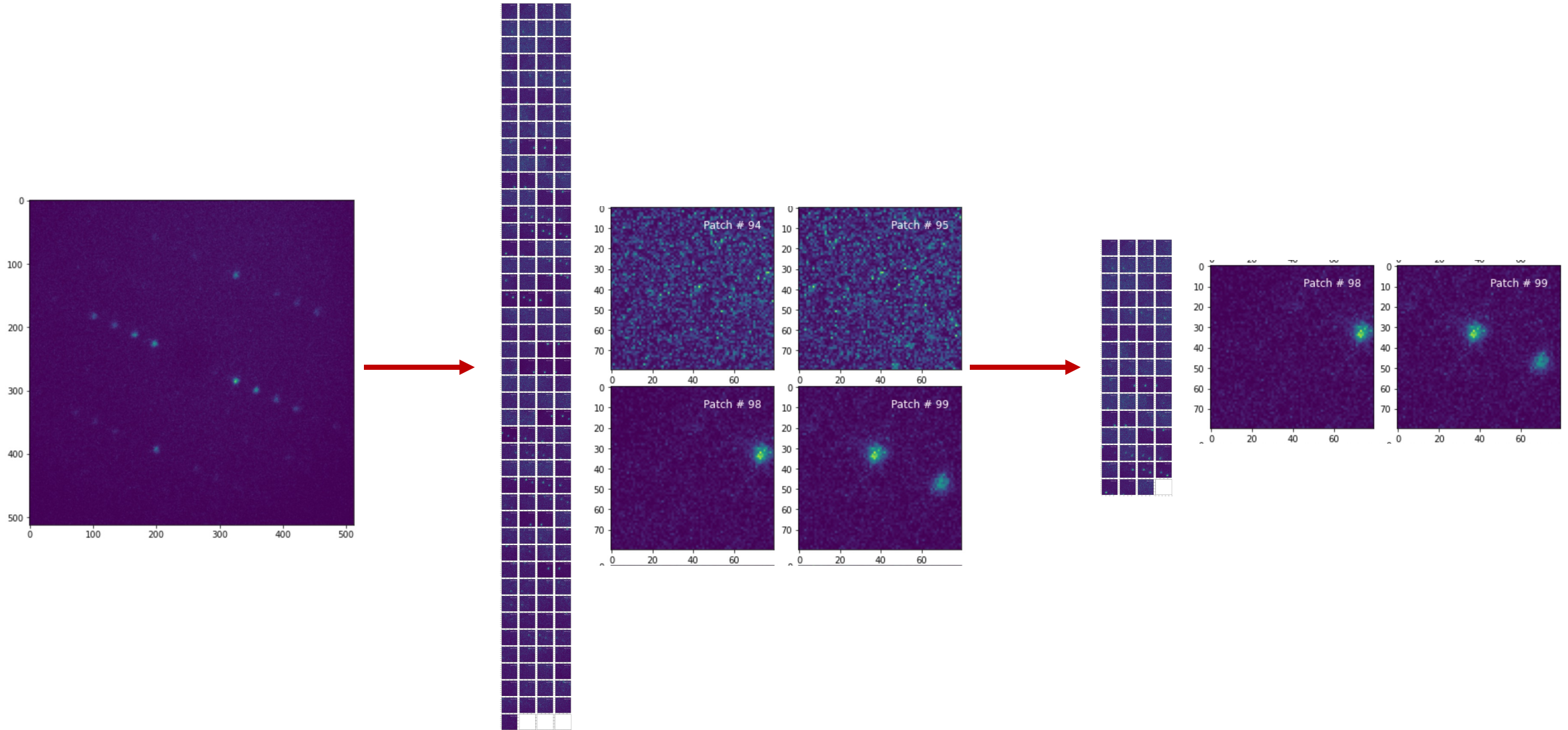
$$IPR = \sum_{i=1}^N f(x)^2$$

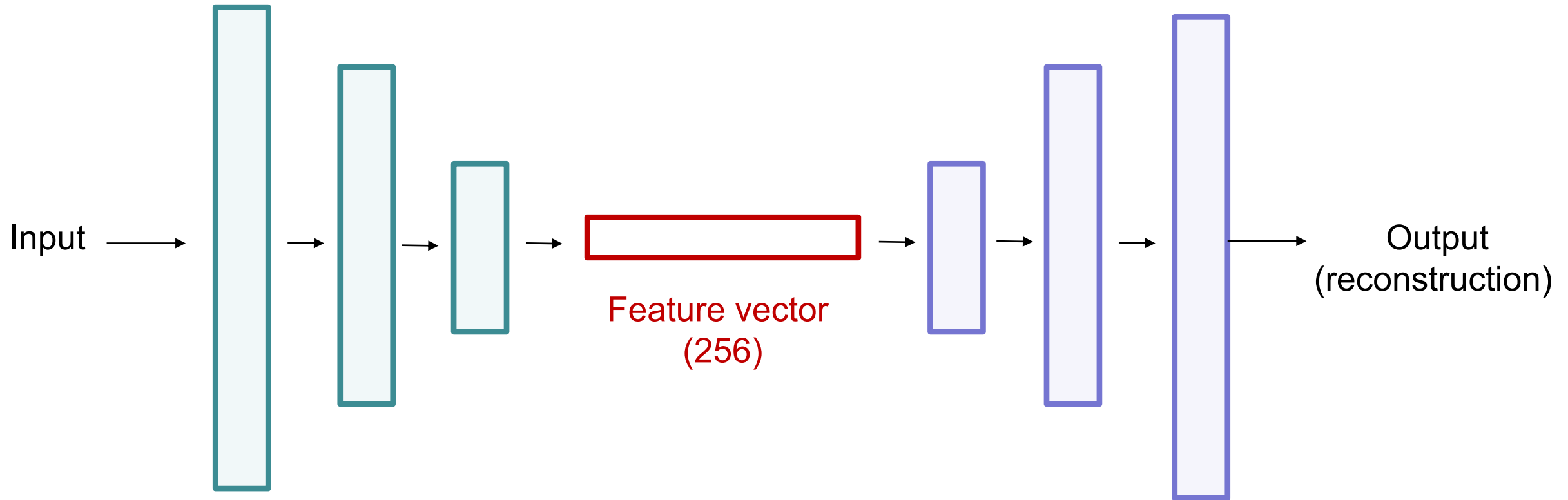
For white noise, all frequencies contribute equally so $f(x)$ has the same value for all x then:

$$f_i(x) = 1/N \Rightarrow IPR = \sum_{i=1}^N 1/N^2 = 1/N$$

We do the FFT of the tile, calculate the IPR and if it is equal to $1/N$ the tile is not included in the dataset for the autoencoder.

Preprocessing is key for good ML performance

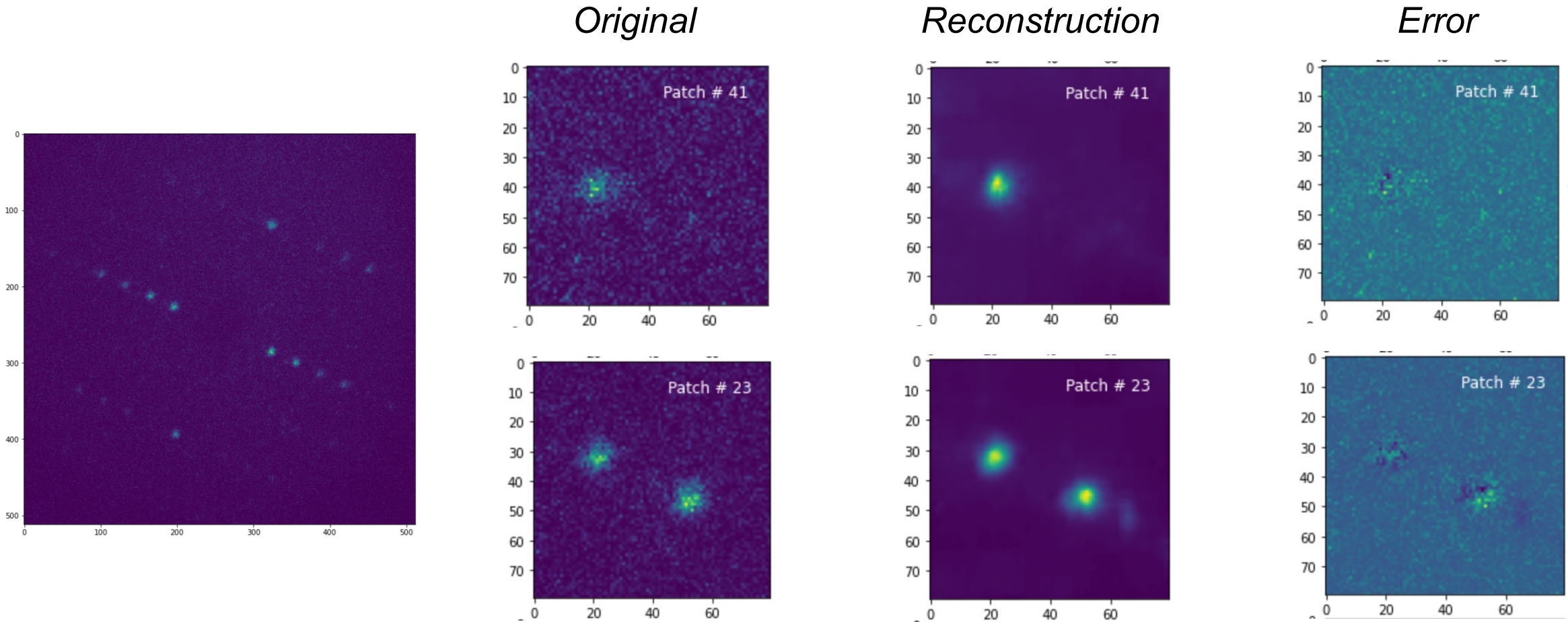




- Each layer of the encoder: Conv2d with relu activation followed by MaxPool.
- MSE loss is used, model trained with 3789 diffraction patterns.
- Dataset is split 10-10-80 for test-validation-training.

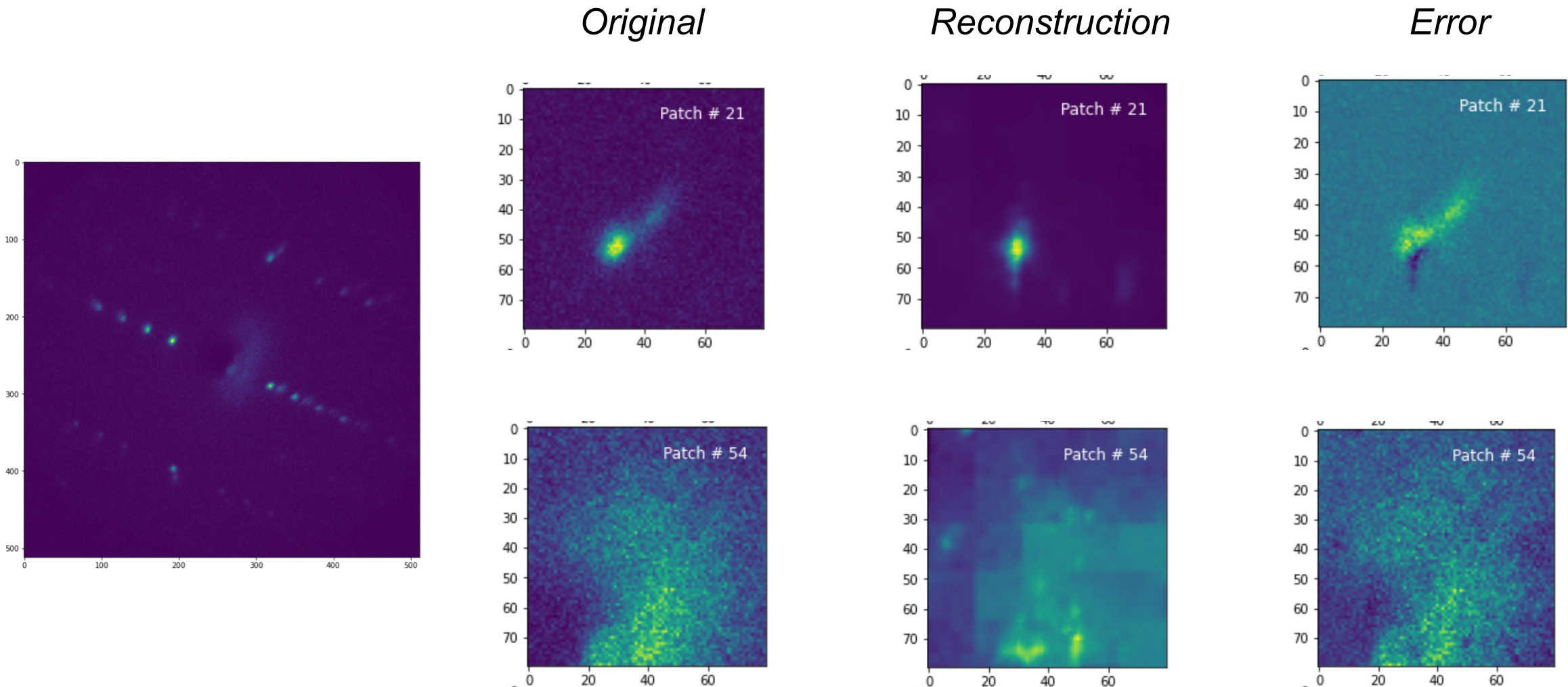
Our autoencoder reproduces and denoises patterns

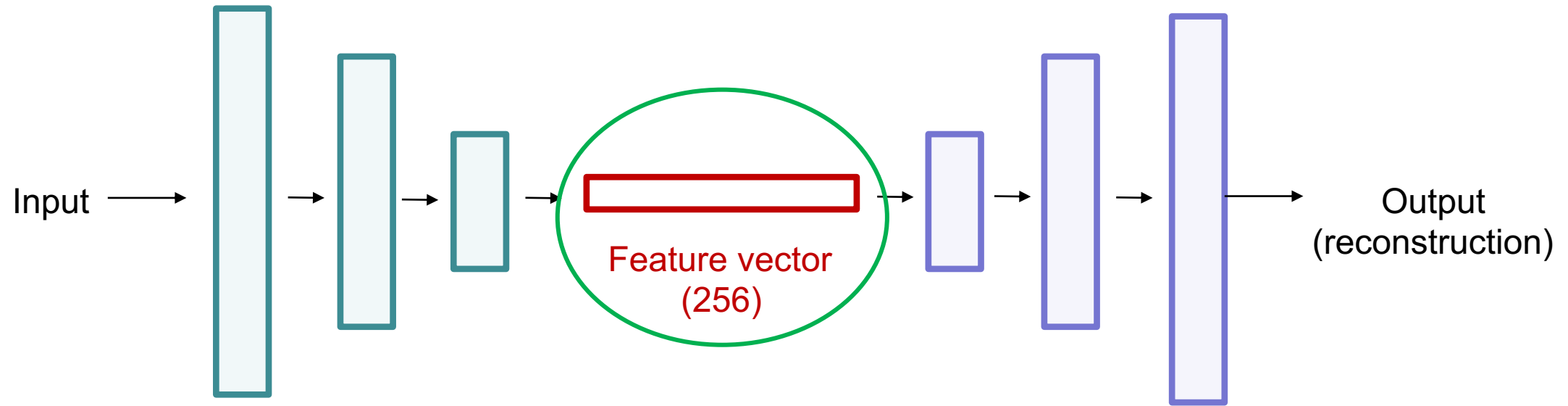
- The autoencoder performs very well and is trained in 100 epochs.
- It also served to denoised the images (which we plan to explore further)



Our autoencoder performs poorly for anomalies

- Recognizable features of anomalies are not well reconstructed:

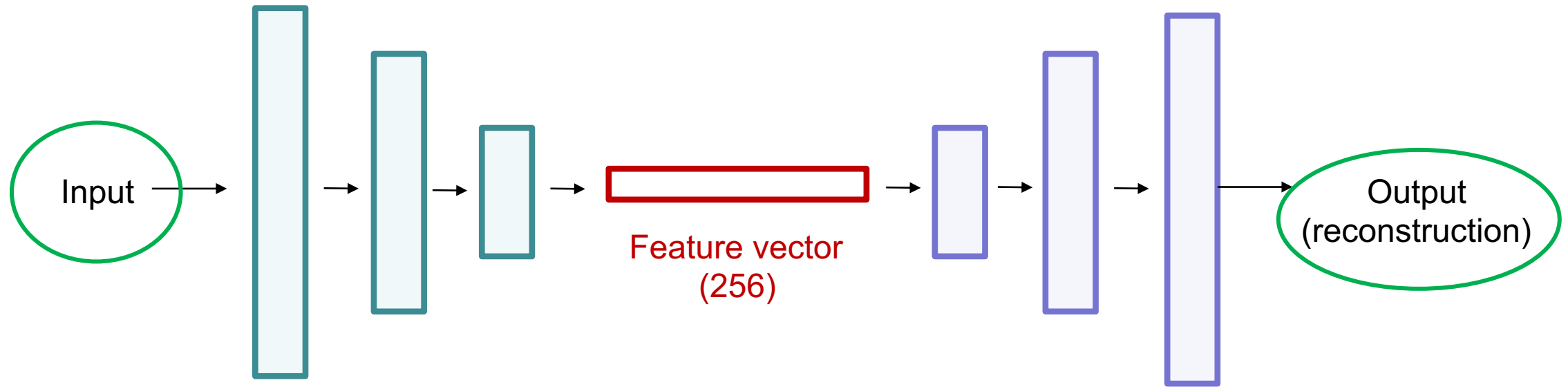




- We implemented a **one-class support vector machine** with Gaussian kernel.
- We estimated the parameters in an **unsupervised** way.

However, we still have much to do:

- We want to use OCSVM in a probabilistic approach.
- We are having issues detecting a class of anomalies related to large energy variations.



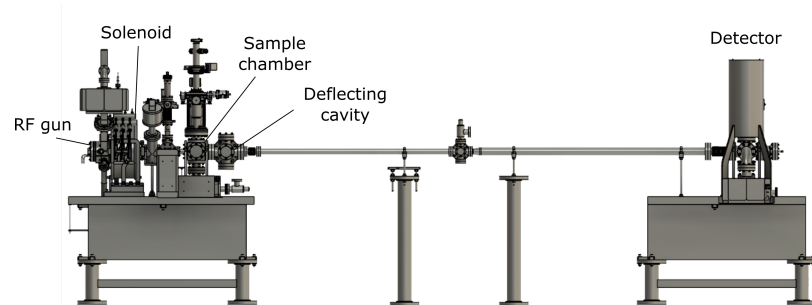
- We can use the **pixel wise error** between input and output.
- We proved that this fits a **Skellam distribution** (only significant source of noise is Poisson)

However, we still have much to do:

- We want to combine both anomaly detection approach for increased confidence.
- We want to set thresholds defined by users needs and tolerances.

Connection to ALCF: two DOE facilities

Accelerator Test Facility (ATF @ BNL)

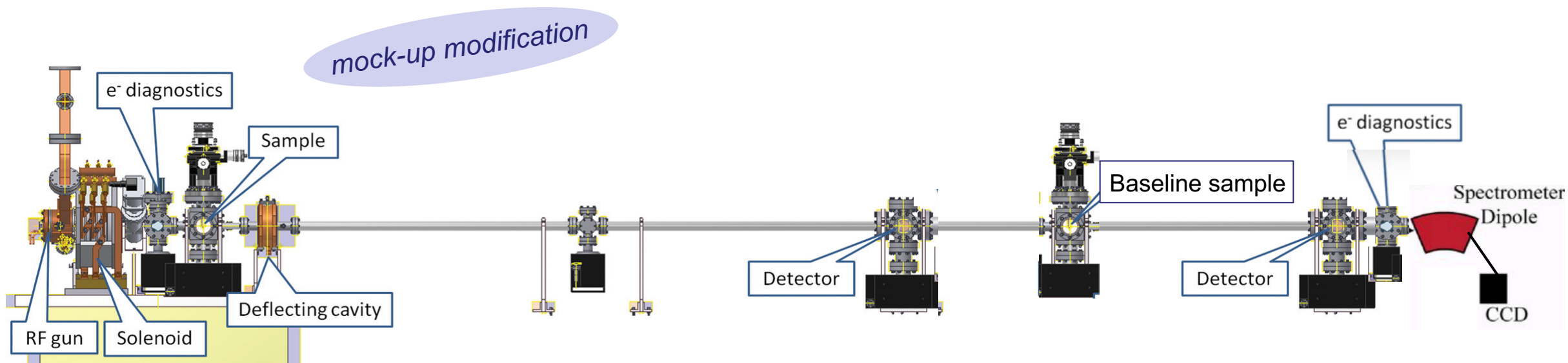


Argonne Leadership Computing Facility (ALCF)



- We have allocation at Theta and ThetaGPU for this experiment.
- We establish connection from a computer in the control room at BNL to ALCF.
- We plan to allow users to train / do inference with the model using ALCF resources for near-real time results (training on single GPU ~ 12 sec/epoch).
- This would be as simple as running a Jupyter notebook (for inference) and we already have custom built code for analysis and instrumental diagnostics.

Future Plans: enabling shot-to-shot with ML



- Add beamline extension to measure concurrent diffraction patterns of a baseline sample. We will use this as a shot-to-shot nondestructive diagnostic tool.
- We plan to employ ML/AI techniques for control of the instrument.
- Simulations of the beamline underway to use a surrogate model for control.

- ✓ We applied a convolutional autoencoder for reconstruction of electron diffraction patterns.
- ✓ The machine performs well and also denoises (great plus!).
- ✓ Both pixel-wise reconstruction error and OCSVM applied to feature vector are good detectors of anomalies.
- ✓ Next step: combining both approaches for more robust (and tunable) anomaly detection.
- ✓ We established a workflow for data originating from ATF to stream to ALCF.
- ✓ Upcoming: applying the machine to other materials. Interested in MUED? If so, **biedron@unm.edu**

Thank you for your attention

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